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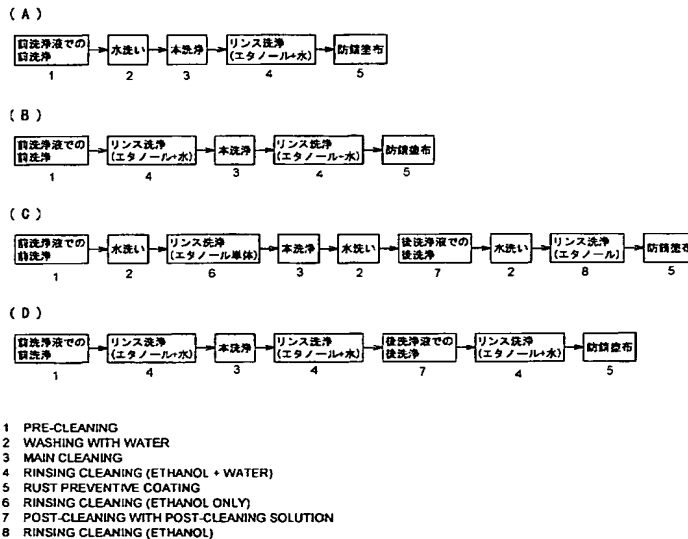
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(54) Title: MOLD CLEANING SOLUTION, MOLD CLEANING METHOD AND MOLD CLEANING APPARATUS

(54) 発明の名称: 金型洗浄液、金型洗浄方法および金型洗浄装置



(57) Abstract: A method for cleaning a mold, wherein a main cleaning solution for use in the electrolytic cleaning as a main cleaning comprises a strongly alkaline component containing one or more selected from sodium hydroxide, potassium hydroxide and sodium carbonate, a chelating agent comprising EDTA 4-sodium salt, an oxidized material removing component comprising an organic or inorganic nitrogen, and sodium gluconate, wherein a purified water is used for the preparation of said main cleaning solution, which results in that the present method is suitable for the cleaning of a nickel mold used for molding a fine molded article, and wherein when a pre-cleaning is carried out before the electrolytic cleaning as a main cleaning, use is made of a pre-cleaning solution comprising a nonionic, cationic or anionic surfactant, sodium metasilicate and/or sodium orthosilicate and a chelating agent.

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